Awards

Society Awards



The **OLIN PALLADIUM AWARD** was established in 1950 for distinguished contributions to the field of electrochemical or corrosion science. The award consists of a palladium medal, a plaque, and a prize of \$7,500. The next award will be presented at the 212th ECS Meeting in Washington, DC, October 7-12, 2007.

Nominations and supporting documents should be sent to Douglas Hansen, University of Dayton Research Inst., Materials Engineering Division, 300 College Park, K1162, Dayton, OH 45469-0130, USA:, tel: 937.229.4380, fax: 937.229.4686, e-mail: douglas.hansen@udri.udayton.edu. **Materials are due by October 1, 2006.**



The GORDON E. MOORE MEDAL FOR OUTSTANDING ACHIEVEMENT IN SOLID STATE SCIENCE AND TECHNOLOGY was established in 1971 for distinguished contributions to the field of solid-state science. The award consists of a silver medal, wall plaque, and prize of \$7,500. The next award will be presented at the 211th ECS Meeting in Chicago, Illinois, May 6-11, 2007.

Nominations and supporting documents should be sent to Hisham Z. Massoud, Duke University, PO Box 90291, Electrical Computer Eng, Durham, NC 27708-0291, USA; tel: 919.660.5257, fax: 919.660.5293, e-mail: massoud@ee.duke.edu. Materials are due by May 1, 2006.



The **CARL WAGNER MEMORIAL AWARD** was established in 1980 to recognize significant achievements in research in areas of interest to the Society; and significant contributions in guidance and development of students or colleagues in education, industry, or government. The award consists of a Life membership in the Society, a certificate, a silver medal, and travel assistance to the meeting of the award presentation (up to \$1,000). The next award will be presented at the 212th ECS Meeting in Washington, DC, October 7-12, 2007.

Nominations and supporting documents should be sent to John Dukovic, Applied Materials Inc., PO Box 58039, 3050 Bowers Ave M/S 10850, Santa Clara, CA 95054, USA; tel: 408.235.6092, fax: 408.563.6951, e-mail: John_Dukovic@AMAT.com. **Materials are due by October 1, 2006.**

Divison Awards

The **Research Award of The ELECTRODEPOSITION DIVISION** was established in 1979 to recognize outstanding research contributions to the field of electrodeposition. The award consists of a scroll and prize of \$2,000. The next award will be presented at the 210th ECS Meeting in Cancun, Mexico, October 31-November 3, 2006.

Nominations and supporting documents should be sent to the award chair, Jay A. Switzer, University of Missouri-Rolla, 103 Materials Research Center, Chemistry Dept, Rolla, MO 65401, USA; tel: 573.341.4383, fax: 573.341.2071, e-mail: jswitzer@umr.edu., **Materials are due by April 1, 2006.** The **ELECTRONICS AND PHOTONICS DIVISION Award** was established in 1968 to encourage excellence in electronics research and outstanding technical contribution to the field of electronics science. The award consists of a scroll, a prize of \$1,500, and travel expenses or life membership in the Society. The next award will be presented at the 211th ECS Meeting in Chicago, Illinois, May 6-11, 2007.

Nominations and supporting documents should be sent to Yue Kuo, Texas A&M University, Chem Eng MS 3122, 335-0 Zachry Engineering Center, College Station, TX 77843-3122, USA; tel: 979.845.9807, fax: 979.458.8836 e-mail: yuekuo@tamu.edu. **Materials are due by August 1, 2006.** The **Research Award of the Energy Technology Division** was established in 1992 to encourage excellence in energy related research. The award consists of a scroll, a prize of \$1,500, and membership in the Energy Technology Division as long as a member of ECS. The next award will be presented at the 211th ECS Meeting in Chicago, Illinois, May 6-11, 2007.

Nominations and supporting documents should be sent to Margaret A. Ryan, Jet Propulsion Laboratory, 4800 Oak Grove Drive, #198-235, Pasadena, CA 91109-8001, USA; tel: 818.354.8028, fax: 818.393.5007, e-mail: mryan@jpl.nasa. gov. **Materials are due by October 1, 2006.**

Highlight on the IE&EE Division's New Electrochemical Technology (NET) Award

Nominations are sought for the New Electrochemical Technology (NET) Award of the Industrial Electrolysis and Electrochemical Engineering Division. The NET Award was endowed by the Dow Chemical Company Foundation to recognize significant advances in industrial electrochemistry. When new technology is introduced into the marketplace today, it is usually the result of a collaborative effort. The primary motivation in establishing this award is to promote high quality applied electrochemical research and to recognize the role of multidisciplinary teams in developing ideas into technology. The next award will be presented during the business luncheon of the IE&EE Division at the spring 2007 ECS meeting in Chicago, Illinois, USA.

The NET Award consists of a commemorative plaque with appropriate inscription that will be presented to the organization sponsoring the technology. Up to six key contributors to the success of the technology development, as identified by the sponsoring organization, will be recognized individually.

The primary award criterion is technological impact on the industrial

practice of electrochemistry. Award applicants will include published papers and issued patents, plus other documentation as noted on the nomination form. To be considered, the technology must have been commercialized within 10 years of the award date. Commercial advances involving applied electrochemical science as a major development vehicle are eligible for consideration. Award preferences may be given to technological achievements in areas particularly served by the IE&EE Division.

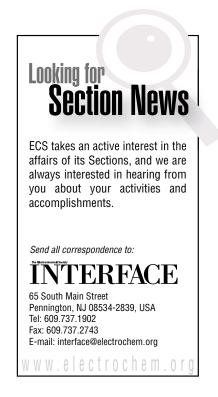
Past recipients of the award include: the Asahi Glass Company in 1999; and De Nora Tecnologie Elettrochimiche, E-Tek, and Bayer Material Science AG in 2005.

The deadline for the receipt of nominations is May 1, 2006. More information, including nomination forms, is available from ECS or the chair of the IE&EE Division NET Award committee: Dennie T. Mah, DuPont Company, 2609 Majestic Drive, Wilmington, DE 19810-2430, USA, tel: 302.774.4264, cell: 302.367.6475, fax: 302.774.2457, e-mail: doctor_ electro@msn.com.

Section Awards

The Heinz Gerischer Award of the **EUROPEAN SECTION** was established in 2001 to recognize an individual or a small group of individuals (no more than three) who have made an outstanding contribution to the science of semiconductor electrochemistry and photoelectrochemistry including the underlying areas of physical and materials chemistry of significance to this field. The award consists of a plaque and a check for €2000. The winner will be invited to deliver the "Gerischer Prize Lecture" during the international meeting at which the prize will be presented.

Nominations and supporting documents should be sent to Claude Levy-Clement, LCMTR, CNRS UPR 209, 2-8 rue Henri Dunant, Thiais 94320, France; tel: 33.149781331, fax: 33.149781203, e-mail: levy-clement@ glvt-cnrs.fr. **Materials are due by September 30, 2006.**



NOTICE:

IE&EE NET Award Deadline Extended to July 1

Call for Nominations

For details on each award, including a list of requirements for award nominees, and in some cases, a downloadable nomination form, please go to the ECS website (www.electrochem.org) and click on the "Awards" link in the upper right-hand corner. This will take you to a general page that will then lead to the individual awards. The awards are grouped in one of four categories: Society Awards, ECS Division Awards, Student Awards, and ECS Section Awards. Click on one of these sub-links to find the individual award. Please see each for information about where-nomination materials should be sent; or you may contact the ECS headquarters office by using the contact information on the awards web page. For student awards, please see the Student News Section in this issue.